<u>PATENT</u>

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

pplicant: Kie Y. Ahn et al.

Examiner: Maria Guerrero

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Group Art Unit: 2822

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Title:

POROUS SILICON OXYCARBIDE INTEGRATED CIRCUIT INSULATOR

AMENDMENT AND RESPONSE UNDER 37 CFR § 1.111

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

This paper responds to the Office Action mailed on <u>September 16, 2003</u>. Please amend the above-identified patent application as follows.

This response is accompanied by a Petition, as well as the appropriate fee, to obtain a three-month extension of the period for responding to the Office Action, thereby moving the deadline for response from December 16, 2003 to March 16, 2004.